



**PATENT**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

**In re Application of:**

Gurtej S. Sandhu

**Serial No.:** 09/023,146

**Filed:** February 12, 1998

**For:** TUNGSTEN SILICIDE (WSIx)  
DEPOSITION PROCESS FOR  
SEMICONDUCTOR MANUFACTURE

**Examiner:** T. Dang

**Group Art Unit:** 2823

**Attorney Docket No.:** 3369.1US  
(91-365-RE)

**NOTICE OF EXPRESS MAILING**

Express Mail Mailing Label Number: EL740533024US

Date of Deposit with USPS: April 20, 2001

Person making Deposit: Jared Turner

RECEIVED  
APR 30 2001  
TC 2800 MAIL ROOM

**SUBMISSION UNDER 37 C.F.R. §1.114**

Box RCE  
Commissioner for Patents  
Washington, D.C. 20231

Sir:

The following amendments and remarks are filed in response to Examiner's remarks in the Advisory Action mailed March 16, 2001 and to the Examiner's remarks in the Final Office Action mailed December 20, 2000, the three-month shortened statutory period for response to which expired on March 20, 2000. These remarks are filed within one month of the shortened statutory period for response. A petition for an extension of time and a check in the amount of \$110.00 for a one month extension of time for response is included herewith.